On the Electronic Transport M echanism in Conducting Polymer N ano bers

Natalya A. Zim bovskaya^y, A lan T. Johnson, Jr.^z, and Nicholas J. Pinto^y

^yD epartm ent of Physics and Electronics, University of Puerto Rico at Hum acao,

Hum acao, PR 00791, and ^{z}D epartm ent of Physics and A stronom y,

University of Pennsylvania, Philadelphia, PA 19104-6396

(D ated: A pril 14, 2024)

Here, we present theoretical analysis of electron transport in polyaniline based (PAN i) nano bers assuming the metalic state of the material. To build up this theory we treat conducting polymers as a special kind of granular metals, and we apply the quantum theory of conduction in mesoscopic systems to describe the transport between metallic-like granules. Our results show that the concept of resonance electron tunneling as the predominating mechanism providing charge transport between the grains is supported with recent experiments on the electrical characterization of single PAN in ano bers. By contacting the proposed theory with the experimental data we estimate some important parameters characterizing the electron transport in these materials. Also, we discuss the origin of rectifying features observed in current-voltage characteristics of bers with varying cross-sectional areas.

PACS num bers: 72.80.-r

Starting from their discovery, conducting polymers undergo intense research. These materials are signi cant mostly due to various possible applications in fabrication of nanodevices, for polymer based devices should have advantages of low cost and exible, controlled chem – istry [1]. Also, there are some unsolved problems concerning physical nature of charge transfer mechanisms s in conducting polymers making them interesting subjects to fundamental research. Recently, we reported of fabrication of doped polyaniline/polyethylene oxides (PAN i/PEO) nano bers using electrospinning technique [2, 3]. The details of the electrospinning setup used for the bers fabrication are described elsewhere [2, 4].

Single ber electrical characterization was carried out at room temperatures (T 300 K). It was revealed in the experim ents that current-voltage curves for conducting PANi bers could be non-ohm ic. Field-e ect transistor (FET) saturation behavior was observed in the device made out of two nano bers with the diam eters 300 nm and 120 nm, respectively, placed across two gold electrodes [2] on a doped Si/SiO₂ water in a FET con guration. As well, nonlinear current-voltage curves were obtained in trasport experiments on thinner nano bers [3]. Som e characteristics appeared to be asym m etric with respect to the reversal of the applied bias voltage polarity, especially those for bers of varying diameter. We do believe that these experim ental results contain in portant information concerning physical mechanisms of the charge transport in conducting polymers. In the present work we concentrate on the theoretical analysis of the previous experim ental results to recover this inform ation.

C onducting chem ically doped polymers are known to be very inhom ogeneous. In some regions polymer chains are disordered, forming amorphous poorly conducting substance. In other regions the polymer chains are ordered and densely packed [5, 6]. These regions behave as metallic-like grains embedded in a disordered amorphous environm ent. This gives grounds to apply the model of a granular m etal [7] to describe such materials. The fraction of metallic-like islands in bulk polymers varies depending on the details of synthesis process. P resumably, in actual samples the metallic grains always remain separated by poorly conducting disordered regions and do not have direct contacts. W ithin this model electronic states are assumed to be delocalized over the grains, therefore electrons behave as conduction electrons in conventional metals. Their motion inside the grains is di usive with the di usion coe cient $D = \frac{1}{3}v_F^2$ (v_F is the Fermi velocity, and is the scattering time).

Recently, Prigodin and Epstein (PE) suggested that the grain-to-grain transport mostly occurs due to the resonance tunneling of electrons. The latter is provided with interm ediate states on the chains connecting the grains [B]. In the present work we further develop the PE approach to the charge transport in conducting polymers, and we show that it brings results consistent with those obtained in transport experiments on individual PAN i nano bers [2, 3].

W ithin this approach we immediately see a similarity in electron transport mechanisms in conductive polymers and those in molecular wires connecting metal leads [9]. In both cases the transport is mostly provided by intervening "bridges" giving rise to intermediate states for the electron tunneling. Employing the granular metal model we can treat metallic islands as "leads" connected with single-site bridges. This simple structure of the bridges is proposed in PE theory. We also explain the issue below. A systematic theory of conductance in quantum molecular wires is developed during the last two decades. In further analysis we employ this theory. A coordingly, we write an electric tunneling current owing between two crystalline domains I_{ig} in the form [10]:

$$I_{ig} = \frac{2e}{h} \begin{bmatrix} I & I & I \\ I & dE T_{eff} (E) & f_1 (E) & f_2 (E) \end{bmatrix} : (1)$$

Here, $f_{1;2}$ (E) are Ferm i functions taken with di erent contact chem ical potentials for the grains: 1 and 2; respectively. The chem ical potentials di er due to the voltage W applied between the grains [11]:

$$_{1} = E_{F} + (1) e W; _{2} = E_{F} e W: (2)$$

The dimensionless parameter characterizes how the voltage is divided between the grains, $E_{\rm F}$ is the equilibrium Fermi energy of the system, and $T_{\rm eff}$ (E) is the electron transmission function.

In general, the electron transm ission function $T_{\rm eff}$ (E) includes a term T (E) describing coherent transport by electron tunneling along with inelastic contribution originating from motions in the medium between the grains. These motions, especially nuclear motions in the resonance chain, could cause the electronic phase breaking e ect. In our case "the bridge" is a single electron level situated between the grains.

For the considered problem the electron transport is a combination of tunneling through two barriers (the st one separates the left m etallic dom ain from the interm ediate state in the middle of the resonance chain, and the second separates this state from the right grain, supposing the transport from the left to the right) a ected with the inelastic scattering at the bridge, as shown below. The barriers are represented by the squares, and the triangle in between in itates a scatterer coupling the bridge to a dissipative electron reservoir.

$$1 \xrightarrow{\underline{b_1}} \underbrace{a_1}_{a_1^0} \# c \underbrace{a_2}_{c} \underbrace{b_2}_{a_2^0} 2$$

A n electron could be injected into this system, and/or leave from there via four channels indicated in this schematic drawing. Incoming particle uxes (J) are related to those outgoing from the system (J_j^0) by means of the transmission matrix T [12, 13]:

$$J_{j}^{0} = \prod_{i}^{K} T_{ji} J_{i}; \quad 1 \quad i; j \quad 4:$$
(3)

0 diagonalm atrix elements $T_{\rm ji}\left(E\right)$ are probabilities for the electron to be transmitted from the channel i to the channel j; whereas diagonalm atrix elements $T_{\rm ii}\left(E\right)$ are probabilities for its rejection back to the channel i [14]. To provide the charge conservation, the net particle ux in the channels connecting the system with the reservoir, must be zero. So, we have:

$$J_3 + J_4 \quad J_3^0 \quad J_4^0 = 0$$
: (4)

W e have no grounds to believe that there is di erence between the channels 3 and 4, therefore we assume $J_3 =$

 J_4 : A lso, in the following calculations we put $J_2 = 0$; presuming no income ux in the channel 2.

Now, we employ (3) to express outgoing uxes in terms of incoming ones, and we substitute the results into the equation (4). This gives:

$$J_3 = J_4 = J_1 \frac{K_1 (E)}{2 R (E)}$$
 (5)

Here,

$$K_1 (E) = T_{31} + T_{41};$$

 $R (E) = T_{33} + T_{44} + T_{43} + T_{34};$ (6)

The transmission function $T_{\rm eff}$ (E) relates the particle ux outgoing from the channel 2 to that incoming to the channel 1, namely:

$$J_2^0 = T_{eff} (E) J_1$$
: (7)

So, using Eqs.(3), (5) we obtain:

$$T_{eff} = T (E) + \frac{K_1(E)K_2(E)}{1 R(E)};$$
 (8)

where

$$T (E) = T_{21}; K_2 (E) + T_{23} + T_{24};$$
 (9)

The functions T (E); K $_{1;2}$ (E) and R (E) are expressed in terms of the matrix elements of the scattering matrix S relating outgoing wave am plitudes $b_1^0; b_2^0; a_3^0; a_4^0$ to the incident ones $b_1; b_2; a_3; a_4$: $T_{ij} = \beta_{ij} f$: In the considered case the S matrix takes the form $\ [14, 15]$:

$$S = Z \stackrel{1}{\overset{1}{\overset{0}{\overset{0}{\overset{0}{\overset{0}{}}}}} = Z \stackrel{1}{\overset{1}{\overset{0}{\overset{0}{\overset{0}{}}}} = Z \stackrel{1}{\overset{1}{\overset{0}{\overset{0}{}}} = Z \stackrel{1}{\overset{1}{\overset{0}{\overset{0}{}}} = Z \stackrel{1}{\overset{1}{\overset{0}{\overset{0}{}}} = Z \stackrel{1}{\overset{1}{\overset{0}{}} = Z \stackrel{1}{\overset{1}{\overset{0}{}} = Z \stackrel{1}{\overset{1}{\overset{0}{}} = Z \stackrel{1}{\overset{1}{\overset{0}{}} = Z \stackrel{1}{\overset{1}{\overset{1}{}} = Z \stackrel{1}{\overset{1}{}} = Z \stackrel{1}{} = Z \stackrel{1}{ } = Z \stackrel{1}{} =$$

where Z = 1 ${}^{2}r_{1}r_{2}$; $= {}^{P}\overline{1}$; $= {}^{P}\overline{1}$; $r_{1;2}$ and $t_{1;2}$ are the amplitude transmission and rejection coeccients for the barriers $(j_{1;2}f + j_{1;2}f = 1)$; and the parameter characterizes the dephasing strength. This parameter takes values within the range [0;1]; = 0 corresponding to the completely coherent, and = 1 to the fully incoherent transport, respectively.

W hen the bridge is detached from the dephasing reservoir $T_{eff}(E) = T(E)$: In this case we can employ a simple analytical expression for the electron transm ission function [16, 17, 18]:

$$T(E) = 4_{1}(E)_{2}(E) f_{3}(E) f_{3};$$
 (11)

where:

1,2 (E) Im 1,2 (E) =
$$\frac{V_{1,2}^2}{E_{1,2}}$$
: (12)

Self-energy terms $_{1;2}$ appear due to the coupling of the m etallic grains ("leads") to the bridge, and $V_{1;2}$ are the corresponding coupling strengths. The form of these terms originates from a frequently used model where the grains are simulated with sem in nite hom ogeneous chains. The parameters $_{1;2}$ represent self-energy corrections of the chains. In further analysis we estimate $_{1;2}$ at the energies close to the Fermi energy E_F ; which

brings the result: $_{1,2}$ $iV_{1,2}^2 = _{1,2}$ [13]. Here, $_{1,2}$ is the coupling strength in the chains in itating the m etallic grains.

The retarded G reen's function for a single site bridge could be approximated as follows [19]:

$$G(E) = \frac{1}{E E_1 + i}$$
 (13)

where E_1 is the site energy. The width of the resonance level between the grains is described with the parameter = 1 + 2:

C om paring the expressions (8) and (11) in the lim it = 0 we arrive at the follow ing expressions for the tunneling parameters $_{1,2}$ (E):

$$t_{1;2} (E) = \frac{2}{(E - E_1)^2 + 2} :$$
 (14)

U sing this result we easily derive the general expression for the electron transmission function:

$$T_{eff}(E) = \frac{g(E)(1+2)g(E)(1+2)+1}{[g(E)(1+2)+1+2]^2}$$
(15)

where $g(E) = t_1(E)t_2(E)$:

In further calculations we keep in m ind that the transm ission coe cient for the resonance tunneling is determ ined with the probability of nding the resonance state. The latter is estimated as T exp(L=) where L is theaverage distance between the interacting grains, and is the localization length for electrons [8]. It takes values sm all compared to unity but much greater than the transm ission probability for sequental hoppings along the exp(2L=) [20]. The probability for exischains T_h tence of a resonance state at a certain chain is rather low, so only a few out of the whole set of the chains connecting two grains are participating in the process of intergrain electron transport. Therefore one could assume that any two metallic domains are connected with a single chain providing an interm ediate state for the resonance tunneling. All remaining chains could be neglected for they poorly contribute to the transport com pared to the resonance chain.

Realistic PAN inano bersprepared via electrospinning have diam eters in the range 20 100nm and lengths of the order of several microns. This is signi cantly greater than typical sizes of m etal-like grains and intergrain distances, which take on values 5nm [21]. So, we treat a nano ber as a set of parallel channels for the tunneling current, any channel being a sequence of metallic domains connected with resonance chains. The total current in the ber is the sum of the contributions from all these channels. We assume these contributions to be equal. Also, the voltage W applied across the whole ber is a sum of contributions W from sequental pairs of grains along a single channel. We assume as the st approximation W W L=L_f where L_f is the ber length. Since we presume the current to be conserved in any single channel, we can identify the intergrain current I_{ig} given by (1) with the current in the channel. U sing the above approximation for W we express the current in the channel in term softhe net voltage W instead of W:

For certain doping and crystallinity rates the number of channels is proportional to the ber cross-sectional area. In reality, dedoping of the bers due to the contact of their surfaces with atmospheric gases a ects the number of the working channels n. This occurs because the electron localization length decreases in the dedoped surface layers, bringing a crucial fall in the conduction through the channels which run there. As a result these channels become e insulating. The relative number of the insulating channels is greater in thinner nano bers, therefore their conduction (the latter is proportional to the number of working channels) is much stronger reduced due to the dedoping processes, than the conduction of thicker sam ples.

C onducting sam ples studied in the experiments of $[\beta]$ included 70nm diameter nano ber (Sam ple 1), and a pair of 18nm and 25nm diameter bers connected in parallel (Sam ple 2). PAN i nano bers whose diameters were smaller than 15nm appeared to be insulating due to dedoping, as reported in [3]. Therefore we assume that outer layers whose thickness is 8nm are insulating in all bers used in the experiments. A coepting the value 5 nm to estimate both average grain size and intergrain distance and keeping in m ind the elect of dedoping, we

nd that the 70 nm ber in the experiments of $[\beta]$ could include about 30 40 conducting channels and we could not expect more than 2 working channels in the pair of

bers S2: This gives the ratio of conductions 15 20 which is greater than the ratio of cross-sectional areas of the samples ($A_1 = A_2$ 5): The di erence originates from the stronger dedoping of thinner bers.

To calculate the current in the whole nano ber I we multiply the channel in a single current by the number of working channels I = nI_{ig} : In calculations we consider $jV_{1;2}j < j_{1;2}j$ because the coupling strength of the grains to the interm ediate site in between is proportional to a sm all factor exp(L=): As for the magnitude of the coupling strengths $_{1;2}$; we can roughly estimate them as leV: This value is typical (in order) for covalent bonds. To provide a good match of our theory with the experimental data we employ the least square procedure. This brings $V_{1;2} = 3.0 \text{m eV}$ for the 70 mmber (Sample 1) for n = 35; and $V_{1;2} = 2.4 \text{m eV}$ (n = 2) for the pair of

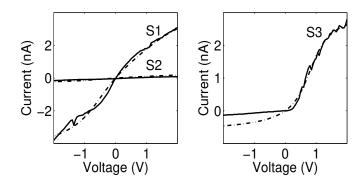


FIG. 1: Calculated (dash-dot lines) and experimental (solid lines) current (nA) { voltage (V) characteristics for PAN i/PEO nano bers (T = 300 K). Experimental characteristics were reported in [3].

thinner bers (Sam ple 2).

The value of the dephasing parameter is determined with the interplay between the characteristics of electronphonon interaction and those of the electron coupling to the leads. W hen the latter is weak, as in the considered case, should depend on energy E exhibiting peaks which correspond to vibrationalm odes in the resonance chain. This was shown in recent papers [18, 19] basing on the nonequilibrium Green's function formalism. These peaks should be revealed in the transm ission function T_{eff} (E) bringing step-like features in the currentvoltage characteristics. The absence of such features in the experimental curves reported in the work [3] gives grounds to believe that in these experiments the relevant energy range does not include phonon harm onics associated with the vibrationalm odes. Therefore, in our calculations we treat as a constant. At a distance from the peaks, the value of is mostly determined with the strength of stochastic m otions in the resonance chain, so this value depends on tem perature. Basing on the results of som e earlier works (see e.g. [13]) concerning electron transport through molecular bridges at room temperature, we assume = 0.05 in our calculations.

O ur results are shown in the Fig.1. The curves S1, S2 present current-voltage characteristics for thick 70nm nano ber (S1), and the pair of thin bers connected in parallel (S2). In plotting the strongly asymmetric curve S3 we put n = 1; and we obtained $V_{1,2} = 3.2m \text{ eV}$: The division parameter value is taken 0.35 for the curve S1. This value is chosen to reproduce slight asymmetry of the corresponding experimental curve. On the contrary, to plot the curve S3 we assume = 0.02 which represents very asymmetric voltage division along the resonance chain.

The asymmetric curve S3 looks like experimental voltampere characteristic reported in [3] for the berwhose diameterwas sharply changing from 70 nm to 20 nm near the middle. The latter did show asymmetric strongly

rectifying volt-ampere curves. We conjecture that sudden change in the ber diam eter produces signi cant changes in the voltage distribution along that segment of the ber where its diam eter changes, a ecting the voltage division between the adjacent m etallic grains located there, so that the major part of the voltage ts the thinner segment. A ssum ing for simplicity that the change in the ber diam eter happens along the segment whose length has the sam e order as intergrain distances, we can roughly estimate the voltage division comparing crosssectional areas of the segments. For the bers used in the experiments of [3] this ratio is 12:5: Recalling the e ects of dedoping on both segments we estimate that voltage division between the segments could be 25:1 which gives for the division parameter at the interface separating the segments estimation: 0:04: This is reasonably close to the value = 0.02 used in plotting the curve S3.

P resented theoretical volt-am pere characteristics reasonably match the curves obtained in the experiments. This justimes the accepted concept of the electron transport in the polymeric granular metals. Also, basing on our results we can estimate values of the coupling strengths $V_{1,2}$: We conclude that the coupling strength of metallic domains to the intermediate state in PAN i have available at 20 and 25 metallic

bers could be estimated as 2:0 3:5 m eV:

F inally, in this paper we apply theory of electron transport through m olecular wires to analyze transport characteristics obtained in experiments on PAN in and bers. D emonstrated agreem ent between the presented theoretical results and experimental evidence proves that electron tunneling between metallic-like grains through intermediate states at the resonance chains really plays a signi cant part in the transport in the conducting polymers provided that they are in the metallic state. This is a novel result which helps to achieve better understanding of physics of metallic state of conducting polymers. Further and more thorough analysis based on the concepts used here promises to bring more information concerning physicalmechanisms and characterictics of transport processes in these substances.

A cknow ledgm ents: W e thank G M.Zimbovsky for help with the manuscript. This work was supported by NSF Advance program SBE-0123654, PR Space G rant NGTS/40091, and NSF-PREM 0353730.

- [1] A.G.MacDianmid, Rev.Mod.Phys.73, 701 (2001).
- [2] N J. Pinto, A T. Johnson Jr., A G. M acD iam id, C H. M ueller, N. Theofylactos, D C. Robinson, and F A. M iranda, Appl. Phys. Lett. 83, 4244 (2003).
- [3] Yangxin Zhou, M. Freitag, J. Hone, C. Stali, A. T. Johnson Jr., N. J. Pinto, and A.G. M adD iarm id, Appl. Phys. Lett. 83, 3800 (2003).

- [4] A G. M adD iam id, W E. Jones, ID. Norris, J.Gao, A.T. Johnson, N.J. Pinto, J. Hone, B. Han, F.K. Ko, H. O kudzaki, and M. Llagino, Synth. Met. 119, 27 (2001).
- [5] J. Joo, Z. Oblakowski, G. Du, JP. Ponget, E J. Oh, JM. W iessinger, Y. M in, A.G. MacDianmid, A J. Epstein, Phys. Rev B 49, 2977 (1994).
- [6] J.P. Ponget, Z. Oblakowski, Y. Nogami, P.A. Albony, M. Laridjani, E.J. Oh, Y. Min, A.G. MacDiarmid, J. Tsukamoto, T. Ishiguro, A.J. Epstein, Synth. Met.65, 131 (1994).
- [7] M. Polak and C.J. Adkins, Phil. M ag. 62, 855 (1992).
- [8] See e.g. V N. Prigodin and A J. Epstein, Synth. M et 125, 43 (2002).
- [9] Concerning transport through molecular wires see e.g. a recent reiew paper: D.R.Bowler, J.Phys.: Condens. M atter 16, R 721 (2004), and references therein.
- [10] S. Datta, Electronic transport in Mesoscopic Systems, (Cambridge University Press, Cambridge, England, 1995).
- [11] S. Datta, W. Tian, S. Hong, R. Reinfenberger, J.H. Henderson and C.P. Kubiak, Phys. Rev. Lett. 79, 2530 (1997).

- [12] L.D 'Am ato and H M .Pastawski, Phys. Rev. B 41, 7411 (1990).
- [13] X in-QiLiand YiLing Yan, Appl. Phys. Lett. 79, 2190 (2001).
- [14] M. Buttiker, Phys. Rev. B 33, 3020 (1986).
- [15] X in-Q i Li and Y iJing Yan, J. Chem . Phys. 115, 4169 (2001).
- [16] M.Kemp, V.Mujica and M.A.Ratner, J.Chem. Phys. 101, 5172 (1994).
- [17] B N J.Persson and A.Barato , Phys.Rev.Lett. 59, 339 (1987).
- [18] T.M ii, S.G. Tikhodeen and H.Ueba, Phys. Rev. B 68, 205406 (2003).
- [19] This approximation is very well known and commonly used. See e.g. M. Galperin, M A. Ratner and A. Nitzan, J. Chem. Phys. 121, 11965 (2004).
- [20] J.Bolton, C J.Lambert, V J.Falko, V N.Prigodin, and A J.Epstein, Phys. Rev. B 60, 10569 (1999).
- [21] R. Pelster, G. N in tz and B. W essling, Phys. Rev. B 49, 12718 (1994).